L Number	Hits	Search Text	DB	Time stamp
-	2	("5,464,792").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/10 15:11
-	50	5464792.URPN.	USPAT	2004/03/08 11:25
-	996	(257/410-411).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/08 11:40
-	1663	(438/216,287,591,954,981).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/08 11:39
-	793	(nitrogen or no) and ((257/410-411).CCLS.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/08 11:41
-	1252	(nitrogen or no) and ((438/216,287,591,954,981).CCLS.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/08 11:41
-	5400	(implanting or implantation) same nitrogen	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/08 11:42
-	87	((implanting or implantation) same nitrogen) and ((257/410-411).CCLS.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/08 11:42
-	152	((implanting or implantation) same nitrogen) and ((438/216,287,591,954,981).CCLS.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/08 11:42
-	223	(((implanting or implantation) same nitrogen) and ((257/410-411).CCLS.)) (((implanting or implantation) same nitrogen) and ((438/216,287,591,954,981).CCLS.))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/08 11:43
-	8	("5674788" | "5789776" | "5969397" | "5981364" | "5998828" | "6180543" | "6246607" | "6342437").PN.	USPAT	2004/03/08 11:49
-	69	5674788.URPN.	USPAT	2004/03/08 11:50
-	16	("4243855" | "4575925" | "5254208" | "5422291" | "5464792" | "5614026" | "5674788" | "5712177" | "5773325" | "5830332" | "5885870" | "5891793" | "5960302" | "6087229" | "6162687" | "6187633").PN.	USPAT	2004/03/08 11:53
-	1	6288432.URPN.	USPAT	2004/03/08 12:15
-	13	("4642878" | "4738934" | "4755865" | "4774197" | "5064775" | "5284795" | "5420056" | "5514902" | "5554871" | "5580800" | "5674788" | "5825066" | "5861335").PN.	USPAT	2004/03/08 12:16
-	55	4774197.URPN.	USPAT	2004/03/08 12:19

C:\APPS\EAST\Workspaces\nitridation implanting gate oxide.wsp

-	2	("5605848").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/09 10:59
-	0	("(implantingwithnitrogen)and((gateadjoxide)oroxynitride	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/09 11:00
-	665	(implanting with nitrogen) and ((gate adj oxide) or oxynitride)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/09 11:01
-	71	(implanting with nitrogen) and ((gate adj oxide) or oxynitride).ti.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/09 11:38
-	2	("5927783").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/09 11:39
-	2	("5972783").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/09 11:39
-	1010	(N or "n.sup.+" or nitrogen or nitric or nitrous or ammonia) near3 (implantation or implant$3) near15 (gate adj (insulat$3 or isolat$3 or dielectric or oxide or dioxide or oxynitride))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/10 15:33
-	2	("5,596,218").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/10 15:33

C:\APPS\EAST\Workspaces\nitridation implanting gate oxide.wsp